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# Graphene Field-Effect Transistor Model With Improved Carrier Mobility Analysis

Jing Tian, Anestis Katsounaros, Darryl Smith, and Yang Hao, *Fellow, IEEE*

**Abstract**—This paper presents a SPICE-like graphene field-effect transistor (GFET) model with an improved carrier mobility analysis. The model considers the mobility difference between the electrons and the holes in graphene, as well as the mobility variation against the carrier density. Closed-form analytical solutions have been derived, and the model has been implemented in Verilog-A language. This was compiled into an advanced design system. The proposed model gives excellent agreement between the simulation results and the measurement data for both the hole and electron conduction simultaneously. The model is suitable for the exploration of GFET-based applications, especially for those using the ambipolar transfer property of GFET.

**Index Terms**—Field-effect transistor (FET), graphene, mobility, Verilog-A.

## I. INTRODUCTION

THE single-atomic-thick nature, high carrier mobility, high thermal conductivity, and ambipolar transfer characteristics make graphene attractive for many electronic applications. Graphene-based ultrabroadband photodetector [1], voltage-tunable terahertz (THz) modulator [2], and broadband millimeter wave absorber [3] have been reported. In [4], the first field-effect transistor (FET) using graphene as the channel material was demonstrated, followed by a 67-nm graphene field-effect transistor (GFET) with an intrinsic cutoff frequency ( $f_T$ ) as high as 427 GHz in [5]. The high carrier mobility of graphene makes it competitive with the III-V high electron mobility transistors, thus indicating great potential in high-frequency applications.

Over the past few years, GFET-based analog/RF circuits [6], [7], active THz [8], and ionizing radiation detectors [9] have been reported. However, an accurate GFET model to predict the device and circuit performance is

still missing. The drift-diffusion GFET model in [10] revealed the physical mechanisms behind the saturation current of the GFETs. However, the accuracy of this model is limited by the accuracy in the calculation of the parameters such as quantum capacitance and saturation velocity. Therefore, a list of work focusing on the theoretical studies [11], [12] and the closed-form analytical solutions [13]–[18] of the GFET modeling were published, providing improved agreement with measurements. A comprehensive model was also reported [19], allowing fast detection of significant physical parameters in the GFET design. Recently, comparisons of existing GFET models were made in [20], leading to a Verilog-A compatible model with the improved accuracy in the vicinity of the Dirac point.

Although these GFET models were in agreement with the measurement data for either electron or hole conduction, modeling of both the conduction modes simultaneously was inaccurate due to the use of identical carrier mobility for both the electrons and the holes. The mobility difference between the electrons and the holes has been observed in many experiments [21]–[23]. This difference can sometimes be as high as 23% [22]. Thus, using the same carrier mobility for the electrons and the holes would cause mismatching for either electron or hole conduction (depending on which mode the model is optimized for). Although there have been reports using distinct mobilities for each of the charge carriers [24]–[26], these models match poorly with the measurement data. Moreover, it has been reported that carrier mobility decreases with the increase in the carrier density in the monolayer graphene [21], [23], but in all the GFET models mentioned above, constant carrier mobility is used.

Therefore, the work presented in this paper aims to create an effective carrier mobility, considering the mobility difference in electron and hole, including the mobility variation against the carrier density. The concept of effective carrier mobility is introduced in Section II. In Section II, based on the comparisons in [20], appropriate approximations for quantum capacitance, charge density, and saturation velocity are chosen. A full derivation of the closed-form analytical solutions of the proposed GFET model is presented in Section III. In Section IV, the modeled results are compared with measurement data. Section V concludes this paper.

## II. ASPECTS OF MODELING

The aim of this paper is to derive accurate closed-form analytical solutions for the intrinsic region of GFET (see the schematic in Fig. 1). Thus, in this section, the approximations

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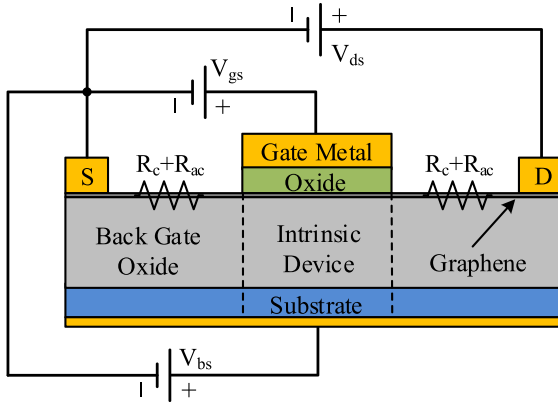


Fig. 1. Cross section of dual-gate GFET modeled in this paper. The channel material is monolayer graphene.  $V_{gs}$ : top-gate voltage.  $V_{bs}$ : back-gate voltage.  $V_{ds}$ : voltage between external drain ( $D$ ) and source ( $S$ ) electrodes. Contact and access resistances ( $R_c$  and  $R_{ac}$ ) are considered as one resistance for both source and drain. Intrinsic device is the region covered by the top gate.

chosen for effective carrier mobility, quantum capacitance, charge density, and saturation velocity should match this criteria while retaining reasonable accuracy. The access and contact resistances are modeled as constant resistors on the drain ( $R_d$ ) and source ( $R_s$ ) sides.

#### A. Charge Density in Graphene Channel

The expressions for the electron and hole densities ( $n$  and  $p$ ) in a graphene channel have been derived as [20]

$$n = \frac{2(kT)^2}{\pi(\hbar v_F)^2} \mathfrak{F}_1\left(\frac{-qV_{ch}}{kT}\right) \quad (1)$$

$$p = \frac{2(kT)^2}{\pi(\hbar v_F)^2} \mathfrak{F}_1\left(\frac{qV_{ch}}{kT}\right) \quad (2)$$

where  $\mathfrak{F}_1(\cdot)$  is the first-order Fermi–Dirac integral,  $q$  is the elementary charge,  $\hbar$  gives the reduced Planck constant,  $v_F$  is the Fermi velocity in graphene,  $k$  is the Boltzmann constant,  $T$  is the temperature, and  $V_{ch}$  is the channel potential. The total net mobile sheet charge density (assuming hole conduction) can be calculated as  $Q_{net} = q \times (p - n)$ .  $Q_{net}$  is used to derive the expression of quantum capacitance and, sometimes, is also used instead of the charge density relevant for transport  $Q_t = q \times (p + n)$  in the calculation of the drain current [11], [14], [15], [18]. According to [20], using  $Q_t$  rather than  $Q_{net}$  in the electronic transport calculation is one way to improve the accuracy of the GFET models. Since there is no closed-form solution for the first-order Fermi–Dirac integral, (1) and (2) have to be solved numerically to achieve the exact solution of  $Q_t$ . In this paper, in order to derive the closed-form analytical solution for the drain current, a simplified expression of  $Q_t$  proposed by [17]

$$Q_t = \frac{q\pi(kT)^2}{3(\hbar v_F)^2} + \frac{q^3 V_{ch}^2}{\pi(\hbar v_F)^2} \quad (3)$$

is used. The relative error between (3) and the exact  $Q_t$  is in the order of  $10^{-5}$ .

In addition to  $Q_t$ , another important fraction of channel charge, which should be taken into account, is the residual

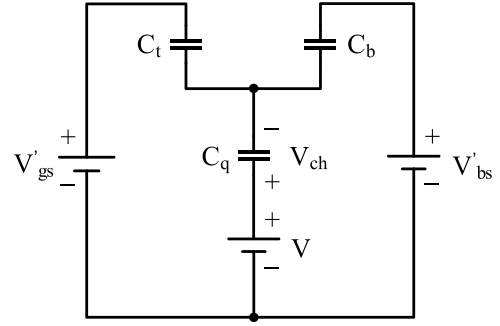


Fig. 2. Equivalent circuit of GFET gate electrostatics describing the relation between gate-oxide capacitances ( $C_t$  and  $C_b$ ) and quantum capacitance  $C_q$ .  $V'_{gs}$ : net top-gate voltage.  $V'_{bs}$ : net back-gate voltage.  $V_{ch}$ : channel potential.  $V$ : voltage drop in the channel.

charge due to electron–hole puddles [21]

$$n_{pud} = \frac{\Delta^2}{\pi(\hbar v_F)^2} \quad (4)$$

where  $\Delta$  is the inhomogeneity of the electrostatic potential. Thus, the total transport sheet carrier density can be written as

$$Q_{tot} = Q_t + q \times n_{pud} \quad (5)$$

which is used later to calculate the drain current.

#### B. Quantum Capacitance

Due to the finite density of states of graphene, the effective gate capacitance  $C_g$  is smaller than the gate-oxide capacitance  $C_{ox}$ . A quantum capacitance  $C_q$  is, therefore, needed in series with  $C_{ox}$  (i.e.,  $C_g = C_q C_{ox} / (C_q + C_{ox})$ ); see Fig. 2 to demonstrate the effective gate capacitance in GFET modeling. The value of quantum capacitance is defined as  $C_q = -(dQ_{net}/dV_{ch})$  [27]. It is a function of the channel potential  $V_{ch}$ , which cannot be neglected for a thin gate oxide. The exact expression for  $C_q$  has been derived as [27]

$$C_q = \frac{2q^2 kT}{\pi(\hbar v_F)^2} \ln \left[ 2 \left( 1 + \cosh \left( \frac{qV_{ch}}{kT} \right) \right) \right]. \quad (6)$$

#### C. Effective Carrier Mobility

The carrier mobility describes how fast carriers can move through the graphene channel under certain electric field. Different mobilities for holes and electrons have been measured in graphene [21]–[23]. In [21] and [23], it has also been shown that the carrier mobility decreases with the increase in the carrier density in the monolayer graphene. Therefore, the effective carrier mobility proposed in this paper should not only consider the hole electron mobility difference but also provide a carrier-density-dependent mobility function for the drain current calculations. Assume that the low field mobilities of electrons and holes are  $\mu_n$  and  $\mu_p$ , respectively. The effective carrier mobility is defined as

$$\mu_{eff} = \frac{n \cdot \mu_n + p \cdot \mu_p + n_{pud} \cdot \hbar}{n + p + n_{pud}} \quad (7)$$

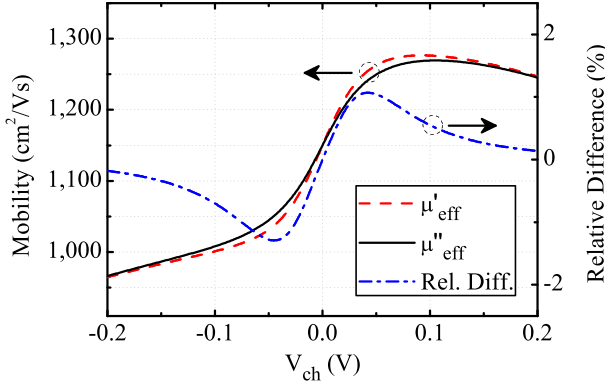


Fig. 3. Left axis: effective carrier mobility as a function of the channel potential  $V_{ch}$ —exact model  $\mu''_{eff}$  and approximation  $\mu'_{eff}$ . Right axis: relative difference between two models. The parameters used in this graph are  $\mu_n = 1000 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 1300 \text{ cm}^2/\text{Vs}$ ,  $m = 1 \text{ V}^2$ , and  $\Delta = 30 \text{ meV}$ .

where  $h = (u_n + u_p)/2$ . Thus, the effective carrier mobility is a function of the channel potential  $V_{ch}$ . Since the carrier mobility of the monolayer graphene decreases with the increase in the carrier density, an additional term derived from the suggested mobility function in [23] is added to (7)

$$\mu'_{eff} = \frac{n \cdot \mu_n + p \cdot \mu_p + n_{pud} \cdot h}{n + p + n_{pud}} \left( \frac{m}{m + V_{ch}^2} \right) \quad (8)$$

where  $m$  is the square of the reference channel potential, used as an empirical fitting parameter. Equation (8) is rather complicated, and does not result in the closed-form analytical solutions for the drain current. Therefore, an approximate function  $\mu_{pn}$  for carriers excluding  $n_{pud}$  (i.e., for  $n + p$  only) is proposed

$$\mu_{pn} = \left( h + \frac{14zV_{ch}}{\sqrt{1 + \left( \frac{qV_{ch}}{kT \ln(4)} \right)^2}} \right) \left( \frac{m}{m + V_{ch}^2} \right) \quad (9)$$

where  $z = (\mu_p - \mu_n)$ . Equation (9) allows calculating the contributions of  $n + p$  and  $n_{pud}$  to the drain current separately, and enables closed-form solutions for the drain current. Thus, the final effective carrier mobility becomes [using the expression of  $Q_t$  from (3)]

$$\begin{aligned} \mu''_{eff} &= \frac{(n + p) \cdot \mu_{pn} + n_{pud} \cdot h \cdot \left( \frac{m}{m + V_{ch}^2} \right)}{n + p + n_{pud}} \\ &= \left( \frac{14z(a + bV_{ch}^2)}{(a + bV_{ch}^2 + n_{pud}) \sqrt{1 + cV_{ch}^2}} + h \right) \left( \frac{m}{m + V_{ch}^2} \right) \end{aligned} \quad (10)$$

where  $a = \pi(kT)^2/(3(\hbar v_F)^2)$ ,  $b = q^2/(\pi(\hbar v_F)^2)$ , and  $c = q^2/((kT \ln(4))^2)$ . In Fig. 3, (8) (red dashed line) and (10) (black solid line) are plotted, as well as the relative difference is defined as  $(\mu'_{eff} - \mu''_{eff})/\mu'_{eff} \times 100\%$ . It can be seen that  $\mu'_{eff}$  and  $\mu''_{eff}$  match very well, and the maximum relative difference is about  $\pm 1.5\%$ , only in this example.

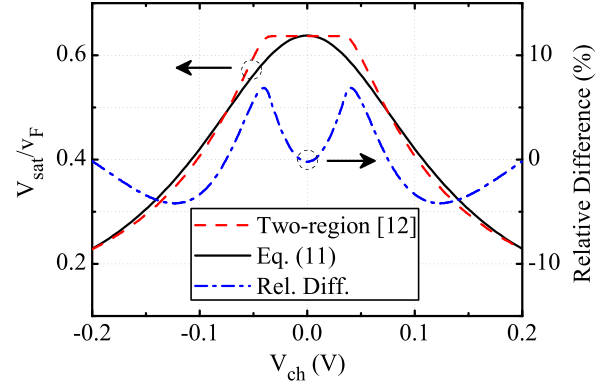


Fig. 4. Left axis: ratio of saturation velocity  $V_{sat}$  to Fermi velocity in graphene  $v_F$  as a function of the channel potential  $V_{ch}$ —two-region model [12] and the proposed approximation. Right axis: relative difference between two models.

#### D. Saturation Velocity

The saturation velocity has been modeled as inversely proportional to the channel potential ( $\propto |V_{ch}^{-1}|$ ) [14], [16]. This approximation provides accurate  $V_{sat}$  at high  $V_{ch}$ , but at low  $V_{ch}$ , it gives unrealistic results (i.e., infinite  $V_{sat}$ ). Therefore, a two-region model was proposed in [12], which agrees well with the  $\propto |V_{ch}^{-1}|$  model at high  $V_{ch}$ . At low  $V_{ch}$ , instead of letting the saturation velocity increase to infinite, the two-region model forces  $V_{sat}$  to be a constant value when the charge density  $Q_{net}$  is smaller than a predefined factor  $\rho_{cri} = \Omega^2/(2\pi v_F^2)$  [12], where  $\Omega$  is a factor along with  $\hbar$  to represent the effective optical phonon emitting energy ( $\hbar\Omega$ ). Thus, the saturation velocity becomes constant around the Dirac point, and this model has also been designed to preserve continuous  $V_{sat}$  at  $\rho_{cri}$  [12]. The comparison of using  $\propto |V_{ch}^{-1}|$  and the two-region model for saturation velocity ( $V_{sat}$ ) has also been discussed in [20].

In spite of these benefits, the two-region model has disadvantages. The main problem has been observed is the discontinuity in the calculated transconductance  $g_m$  (an important parameter widely used in the analog/RF circuit design), and it becomes even more apparent for higher carrier mobility. This occurs due to the sudden change of saturation velocity function at  $\rho_{cri}$ . Although the  $V_{sat}$  is designed to be continuous at  $\rho_{cri}$ , it does not guarantee the continuity of  $g_m$  calculated from  $dI_{ds}/dV_{gs}$ . Meanwhile, the two-region model does not satisfy the requirement of deriving closed-form drain current solutions with (10). Therefore, in this paper, we propose another approximation for  $V_{sat}$

$$V_{sat} = v_F \left( \frac{e}{1 + fV_{ch}^2} + g \right) \quad (11)$$

where  $e = (V_{sat}(\max) - V_{sat}(\min))/v_F$ ,  $f = (q/(5kT))^2$ , and  $g = V_{sat}(\min)/v_F$ . From the two-region model, the values of  $e = 0.58$  and  $g = 0.058$  can be extracted. The  $V_{sat}$  given by (11) consists of only one function, so that the discontinuities in the calculated  $g_m$  are eliminated. In addition, (11) can also be used with (10) to derive the closed-form drain current solutions. Fig. 4 shows the plots

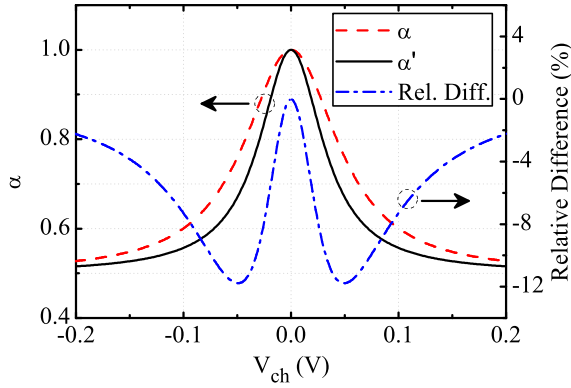


Fig. 5. Left axis: capacitance weighting factor as a function of the channel potential  $V_{ch}$ —exact model  $\alpha$  and approximation  $\alpha'$ . Right axis: relative difference between two models.

of (11) and the two-region model. A relative difference  $((V_{two-region} - V_{sat})/V_{two-region} \times 100\%)$  within  $\pm 7\%$  guarantees the accuracy of the proposed  $V_{sat}$  model.

### III. DERIVATION OF PROPOSED GFET MODEL

This section describes the electrostatics and electronic transport calculation of the proposed GFET model. The drift-diffusion transport model used in this paper is valid when the graphene channel is longer than the mean free path of carriers in graphene. If the channel length is close to or shorter than the mean free path, necessary short-channel effects have to be taken into account.

#### A. Electrostatics

The equivalent circuit describing the gate electrostatics of the dual-gate GFET is shown in Fig. 2. The expression of channel potential can be derived by applying Kirchhoff's laws to this equivalent circuit as [20]

$$V_{ch} = -\frac{(V_{gs} - V_{gs0} - V)C_t + (V_{bs} - V_{bs0} - V)C_b}{C_t + C_b + \alpha C_q} \quad (12)$$

where  $V_{gs}$  and  $V_{bs}$  are the top- and back-gate voltages.  $V_{gs0}$  and  $V_{bs0}$  are the top- and back-gate voltages at which the drain current reaches minimum.  $V$  is the voltage drop in the graphene channel.  $C_t$  and  $C_b$  are the top- and back-gate oxide capacitances, respectively, and  $\alpha$  is the capacitance weighting factor defined as [20]

$$\alpha = \frac{Q_{net}}{C_q V_{ch}} = \frac{kT}{qV_{ch}} \frac{\mathfrak{F}_1\left(\frac{qV_{ch}}{kT}\right) - \mathfrak{F}_1\left(\frac{-qV_{ch}}{kT}\right)}{\ln\left[2\left(1 + \cosh\left(\frac{qV_{ch}}{kT}\right)\right)\right]} \quad (13)$$

From the exact model of  $\alpha$  [i.e., (13)], one can achieve  $\alpha \approx 1$  when  $q \times |V_{ch}| \ll kT$  and  $\alpha \approx 0.5$  when  $q \times |V_{ch}| \gg kT$  [see Fig. 5 (red dashed line)]. So far, many existing GFET models use  $\alpha = 0.5$  for (12), achieving poor accuracy near the Dirac point [20]. In the case of  $\alpha = 1$ , an overestimation would be introduced to the calculated drain current away from the Dirac point. Therefore, an accurate model should contain a transition from  $\alpha = 1$  at  $q \times |V_{ch}| \ll kT$  to  $\alpha = 0.5$  at  $q \times |V_{ch}| \gg kT$ . In this paper, a new model  $\alpha'$  providing

closed-form analytical solutions to (15) is proposed. It is an approximation of (13) and is given as a function of  $V_{ch}$

$$\alpha' = \left(\frac{1}{1 + cV_{ch}^2} + 1\right) \alpha_{min} \quad (14)$$

where  $\alpha_{min} = 0.5$  is the minimum value of  $\alpha$ . In Fig. 5, a comparison of  $\alpha$  and  $\alpha'$  is shown. A maximum relative difference  $((\alpha - \alpha')/\alpha \times 100\%)$  of  $-12\%$  is achieved, which guarantees the accurate transition between  $\alpha = 0.5$  and  $\alpha = 1$  near the Dirac point and is a big improvement compared with the models using constant  $\alpha$ .

Finally, to achieve  $V_{ch}$  and  $C_q$ , (6) and (12) should be solved self-consistently. The iterative Verilog-A algorithm, initially used in carbon nanotube FET models [28], has been extended by Landauer *et al.* [20] to solve self-consistent equations in GFET model successfully. With the iterative Verilog-A algorithm, one is able to let the simulator calculate  $V_{ch}$  automatically, greatly simplifying the GFET modeling. Therefore, in this paper, we follow the way of using the iterative Verilog-A algorithm in [20] to calculate the channel potential at the source and the drain (i.e.,  $V_{cs}$  and  $V_{cd}$ ). During this process, the elementary mathematical approximation of the first-order Fermi-Dirac integral presented in [29] and [30] with a maximum relative error of  $1.79 \times 10^{-6}$  [20] is used.

#### B. Drain Current Calculation

The drift-diffusion model derived in [11]

$$I_{ds} = \frac{W \int_0^{V_{ds}} \mu Q_{tot} dV}{L + \left| \int_0^{V_{ds}} \frac{\mu}{V_{sat}} dV \right|} \quad (15)$$

is used along with the modeling aspects introduced in Section II to calculate the drain current. To derive the closed-form solution for  $I_{ds}$ , an accurate square-root-based approximation proposed by [17]

$$C_q = \frac{2q^2 kT \ln(4)}{\pi (\hbar v_f)^2} \sqrt{1 + \left(\frac{qV_{ch}}{kT \ln(4)}\right)^2} \quad (16)$$

is used in this paper. The comparison between (6) and (16) has been discussed in detail by [20].

Deriving the closed-form analytical solution for the integrals in (15) requires replacing  $dV$  with  $(dV/dV_{ch})dV_{ch}$ . In [20], it is derived from (12) as (using  $\alpha = 1$ )

$$\frac{dV}{dV_{ch}} = 1 + \frac{C_q}{C_t + C_b} \quad (17)$$

neglecting the fact that  $C_q$  and  $\alpha$  are also functions of  $V_{ch}$ . The more accurate expression of  $(dV/dV_{ch})$  (for  $\alpha = 1$ ) using the square-root approximation of  $C_q$  can be derived as

$$\frac{dV}{dV_{ch}} = 1 + d\sqrt{cV_{ch}^2 + 1} + \frac{cdV_{ch}^2}{\sqrt{cV_{ch}^2 + 1}} \quad (18)$$

where  $d = 2q^2 kT \ln(4) / ((C_t + C_b)\pi(\hbar v_f)^2)$ . Using (17) instead of (18) would cause underestimation to the calculated drain current. In [20], this underestimation is compensated by the overestimation caused using  $\alpha = 1$ , resulting in an inaccurate estimation of the drain current.

In this paper, the following expression of  $(dV/dV_{\text{ch}})$  is derived by substituting (16) and (14) into (12), taking the partial derivative of  $V$  against  $V_{\text{ch}}$  on both the sides of the equation. When simplified yields

$$\frac{dV}{dV_{\text{ch}}} = 1 + \frac{ds(2 + cV_{\text{ch}}^2(3 + 2cV_{\text{ch}}^2))}{(1 + cV_{\text{ch}}^2)^{\frac{3}{2}}}. \quad (19)$$

Finally, by substituting (3)–(5), (9), and (19) into (15) and assuming the effective channel potential to be  $(V_{\text{cs}} + V_{\text{cd}})/2$  for  $n_{\text{pud}}$ , the numerator integral of (15) can be rewritten as

$$\begin{aligned} & \int_{V_{\text{cs}}}^{V_{\text{cd}}} q(a + bV_{\text{ch}}^2) \left( h + \frac{14zV_{\text{ch}}}{\sqrt{1 + cV_{\text{ch}}^2}} \right) \left( \frac{m}{m + V_{\text{ch}}^2} \right) \\ & \times \left( 1 + \frac{d\alpha_{\text{min}}(2 + cV_{\text{ch}}^2(3 + 2cV_{\text{ch}}^2))}{(1 + cV_{\text{ch}}^2)^{\frac{3}{2}}} \right) dV_{\text{ch}} \\ & + \int_0^{V_{\text{ds}}} qn_{\text{pud}}h \left( \frac{m}{m + \left( \frac{V_{\text{cs}} + V_{\text{cd}}}{2} \right)^2} \right) dV. \end{aligned} \quad (20)$$

The first term of (20) represents the contribution of  $Q_t$  to the drain current, and the second term represents the contribution of  $qn_{\text{pud}}$  to the drain current. The explicit expression of (20) is achieved with the symbolic calculator in Wolfram Mathematica [31].

Similarly, by substituting (10), (11), and (19) into (15), the denominator integral of (15) can be rewritten as

$$\begin{aligned} & \int_{V_{\text{cs}}}^{V_{\text{cd}}} \frac{1}{v_F} \left( \frac{1 + fV_{\text{ch}}^2}{e + (1 + fV_{\text{ch}}^2)g} \right) \left( \frac{m}{m + V_{\text{ch}}^2} \right) \\ & \times \left( h + \frac{14z(a + bV_{\text{ch}}^2)}{a + bV_{\text{ch}}^2 + n_{\text{pud}}} \frac{V_{\text{ch}}}{\sqrt{1 + cV_{\text{ch}}^2}} \right. \\ & + \frac{hd\alpha_{\text{min}}(2 + cV_{\text{ch}}^2(3 + 2cV_{\text{ch}}^2))}{(1 + cV_{\text{ch}}^2)^{\frac{3}{2}}} \\ & \left. + \frac{d\alpha_{\text{min}}(2 + cV_{\text{ch}}^2(3 + 2cV_{\text{ch}}^2))}{(1 + cV_{\text{ch}}^2)^2} \frac{14zV_{\text{ch}}(a + bV_{\text{ch}}^2)}{a + bV_{\text{ch}}^2 + n_{\text{pud}}} \right) dV_{\text{ch}}. \end{aligned} \quad (21)$$

The explicit expression of (21) is calculated with the same symbolic calculator used above.

#### IV. MODEL VALIDATION

In order to verify the GFET drain current model presented in this paper, the model has been implemented in Verilog-A language and imported in an advanced design system [32]. In this section, the model is first validated against the exact numerical solution results, and the simulated transconductance ( $g_m$ ) is also compared with the model using two-region saturation velocity [20]. Then, the accuracy of the proposed model near the Dirac point is validated by comparing the modeled results with measurement data from a 2.8- $\mu\text{m}$  gate-length GFET [33]. Finally, the sound behavior of the model is compared with a 20- $\mu\text{m}$   $\times$  15- $\mu\text{m}$  ( $L \times W$ )

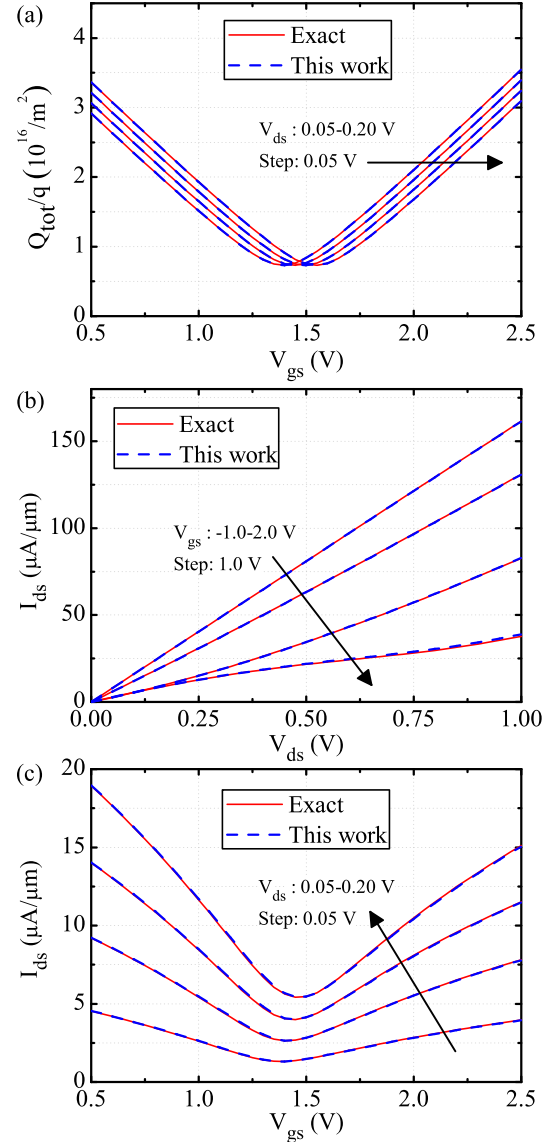


Fig. 6. (a) Charge density on the drain side ( $Q_{\text{tot}}/q$  versus  $V_{\text{gs}}$ ). (b) Output and (c) transfer characteristics of a 5- $\mu\text{m}$  GFET. The results calculated from the analytical model proposed in this paper is compared with the results achieved from the numerical calculation. The parameters used in the model are  $L = 5 \mu\text{m}$ ,  $t_{\text{oxt}} = 15 \text{ nm}$ ,  $k_t = 8.9$ ,  $t_{\text{oxb}} = 300 \text{ nm}$ ,  $k_b = 3.9$ ,  $T = 300 \text{ K}$ ,  $V_{\text{gs}0} = 1.1 \text{ V}$ ,  $V_{\text{bs}0} = 11 \text{ V}$ ,  $\mu_n = 920 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 1330 \text{ cm}^2/\text{Vs}$ ,  $\Delta = 92 \text{ meV}$ ,  $R_{d/s} = 0 \Omega \cdot \mu\text{m}$ , and  $m = 0.1 \text{ V}^2$ .

GFET measured inhouse as well as two other GFETs from [34] and [35] under conventional biasing regions.

##### A. Numerical Versus Analytical Results

The exact GFET model is calculated numerically using the exact model of parameters, such as  $\alpha$  [see (13)],  $C_q$  [see (6)], and  $\mu'_{\text{eff}}$  in both electrostatics and electronic transport calculation. Since the elementary mathematical approximation of the first-order Fermi–Dirac integral has a maximum relative error as small as  $1.79 \times 10^{-6}$ , it is used as the exact model in the numerical calculations. In Fig. 6(a), the exact charge density (at the drain side) against  $V_{\text{gs}}$  under various  $V_{\text{ds}}$  is compared with the results from the proposed

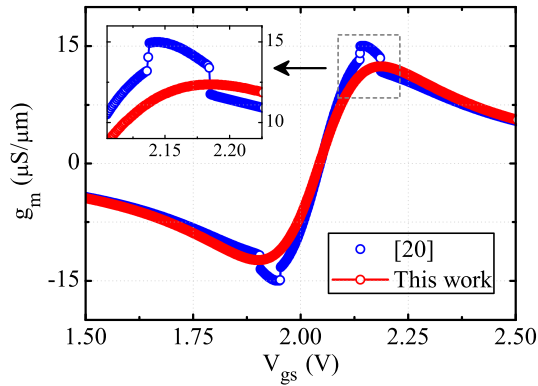


Fig. 7. Comparison of the modeled transconductance  $g_m$  versus top-gate to source voltage  $V_{gs}$  of a 5- $\mu\text{m}$  GFET [34] in this paper and a model with two-region saturation velocity [20]. Parameters used in the model are taken from [20] except the carrier mobility, and they are  $L = 5 \mu\text{m}$ ,  $t_{\text{oxt}} = 15 \text{ nm}$ ,  $k_t = 8.9$ ,  $t_{\text{oxb}} = 300 \text{ nm}$ ,  $k_b = 3.9$ ,  $T = 300 \text{ K}$ ,  $V_{\text{gs0}} = 1.24 \text{ V}$ ,  $V_{\text{bs0}} = 11 \text{ V}$ ,  $\Delta = 100 \text{ meV}$ , and  $R_{d/s} = 3.5 \text{ k}\Omega \cdot \mu\text{m}$  ( $m = 10 \text{ V}^2$  for this paper and  $\hbar\Omega = 75 \text{ mV}$  for [20]).  $\mu_n = \mu_p = 115000 \text{ cm}^2/\text{Vs}$  is used here instead of the original  $1150 \text{ cm}^2/\text{Vs}$  to magnify the discontinuity of  $g_m$ .

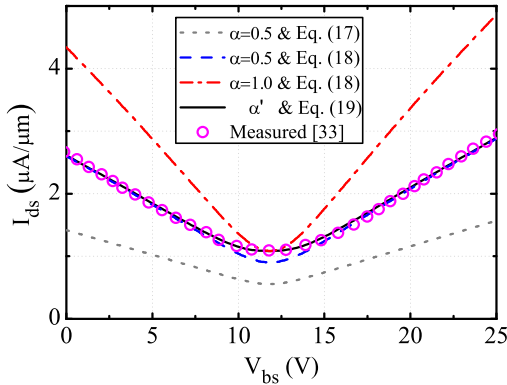


Fig. 8. Comparison of the modeled drain to source current  $I_{\text{ds}}$  versus back-gate to source voltage  $V_{\text{bs}}$  of a 2.8- $\mu\text{m}$  GFET [33] in this paper and models using constant  $\alpha$ . The parameters used in the models are  $L = 2.8 \mu\text{m}$ ,  $t_{\text{oxb}} = 285 \text{ nm}$ ,  $k_b = 3.9$ ,  $T = 300 \text{ K}$ ,  $V_{\text{bs0}} = 11.86 \text{ V}$ ,  $\mu_n = 430 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 410 \text{ cm}^2/\text{Vs}$ ,  $\Delta = 64 \text{ meV}$ ,  $R_{d/s} = 100 \Omega \cdot \mu\text{m}$ , and  $m = 0.5 \text{ V}^2$ .

analytical model for a 5- $\mu\text{m}$  GFET. The curves well overlap with each other, and the maximum relative error is only  $6.77 \times 10^{-4}$ . In addition, the comparisons of output and transfer characteristics illustrated in Fig. 6(b) and (c) also show excellent agreement between the exact and analytical results. The maximum relative error in the calculated  $I_{\text{ds}}$  of this GFET is only 2.89%.

### B. Comparison of Models

The two-region model does give a good description of saturation velocity at  $q \times |V_{\text{ch}}| \ll kT$ . However, it results in discontinuous transconductance in the simulation especially when the carrier mobility is high, and thus is ill suited to model GFETs. Fig. 7 shows the comparison between the simulated  $g_m$  from the model introduced in [20] and the model developed in this paper for a 5- $\mu\text{m}$  GFET measured by [34]. A high carrier mobility (identical for hole and electron) of  $115000 \text{ cm}^2/\text{Vs}$  is used instead of  $1150 \text{ cm}^2/\text{Vs}$  (original

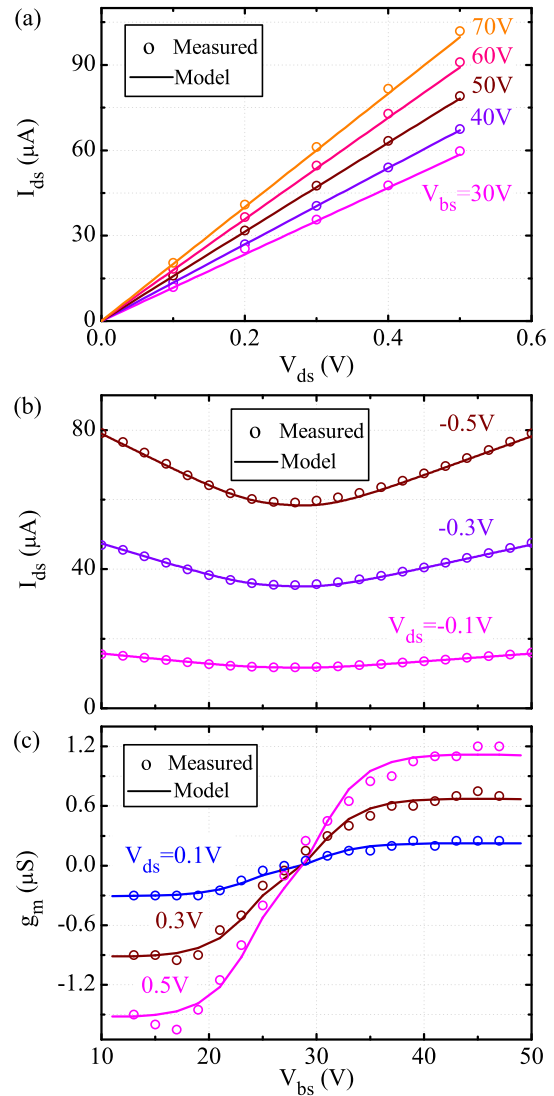


Fig. 9. Modeled output and transfer characteristics of a 20- $\mu\text{m} \times 15\text{-}\mu\text{m}$  GFET versus measurement. (a) Drain-to-source current  $I_{\text{ds}}$  against drain-to-source voltage  $V_{\text{ds}}$  for various back-gate to source voltage  $V_{\text{bs}}$ . (b) Drain-to-source current  $I_{\text{ds}}$  against back-gate-to-source voltage  $V_{\text{bs}}$  for various drain to source voltages  $V_{\text{ds}}$ . (c) Transconductance  $g_m$  against back-gate-to-source voltage  $V_{\text{bs}}$  for various drain-to-source voltages  $V_{\text{ds}}$ . The parameters used in the model are  $L = 20 \mu\text{m}$ ,  $W = 15 \mu\text{m}$ ,  $t_{\text{oxb}} = 500 \text{ nm}$ ,  $k_b = 3$ ,  $T = 300 \text{ K}$ ,  $V_{\text{bs0}} = 27.1 \text{ V}$ ,  $\mu_n = 690 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 940 \text{ cm}^2/\text{Vs}$ ,  $\Delta = 123 \text{ meV}$ ,  $R_{d/s} = 3.75 \text{ k}\Omega \cdot \mu\text{m}$ , and  $m = 1 \text{ V}^2$ .

to magnify the discontinuities in  $g_m$ . It can be seen that discrepancies appear near the maximum and minimum points of  $g_m$  and have been corrected by the proposed model thanks to the improved  $V_{\text{sat}}$  function [see (11)].

In Fig. 8, the simulation results of models using different  $\alpha$  and  $(dV/dV_{\text{ch}})$  functions are also compared with each other. One can see that the simulation results from the model proposed in this paper agree strongly with the measured data from [33]. The model using  $\alpha = 0.5$  and (18) (blue dashed line) differs from the measurement of [33] near the Dirac point and overlaps with the proposed model at high  $V_{\text{ch}}$ . The underestimation (overestimation) caused using (17) ( $\alpha = 1$ ) is shown by gray dotted line (red dashed-dotted line).

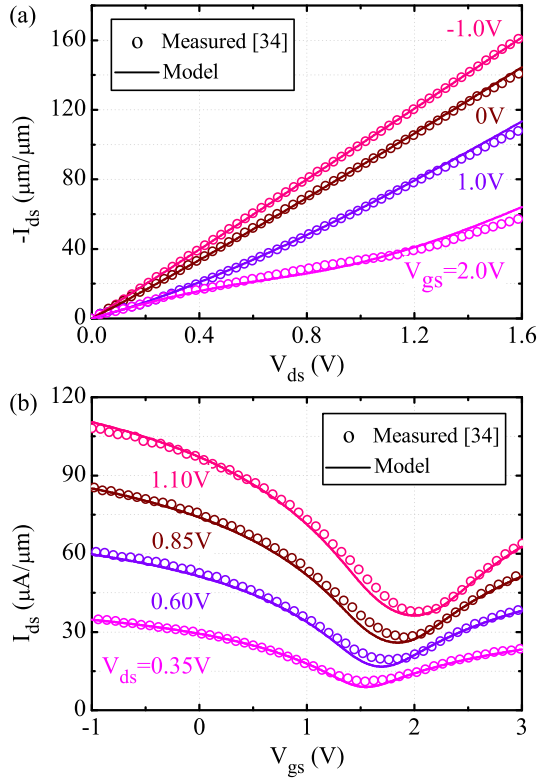


Fig. 10. Modeled transfer characteristics of a 5- $\mu\text{m}$  GFET versus measurement data from [34]. Drain-to-source current  $I_{ds}$  against top-gate-to-source voltages  $V_{gs}$  for various drain-to-source voltage  $V_{ds}$ . The parameters used in the model are  $L = 5 \mu\text{m}$ ,  $t_{\text{ox}t} = 15 \text{ nm}$ ,  $k_t = 8.9$ ,  $t_{\text{ox}b} = 300 \text{ nm}$ ,  $k_b = 3.9$ ,  $T = 300 \text{ K}$ ,  $V_{gs0} = 1.1 \text{ V}$ ,  $V_{bs0} = 11 \text{ V}$ ,  $\mu_n = 920 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 1330 \text{ cm}^2/\text{Vs}$ ,  $\Delta = 92 \text{ meV}$ ,  $R_{d/s} = 2 \text{ k}\Omega \cdot \mu\text{m}$ , and  $m = 0.1 \text{ V}^2$ .

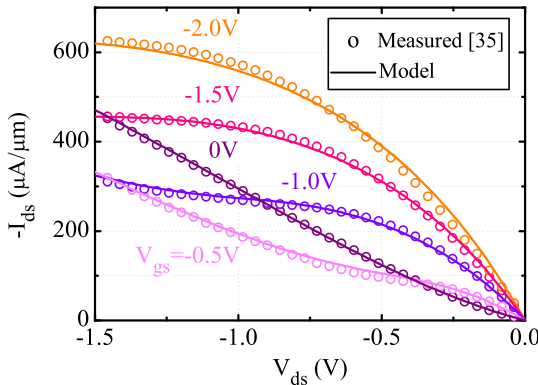


Fig. 11. Modeled output characteristics of a 3- $\mu\text{m}$  GFET against measurement data from [35]. Drain-to-source current  $I_{ds}$  against drain-to-source voltage  $V_{ds}$  for various gate-to-source voltages  $V_{gs}$ . The parameters used in the model are  $L = 3 \mu\text{m}$ ,  $t_{\text{ox}b} = 8.5 \text{ nm}$ ,  $k_b = 3.5$ ,  $T = 300 \text{ K}$ ,  $V_{bs0} = -0.07 \text{ V}$ ,  $\mu_n = 6500 \text{ cm}^2/\text{Vs}$ ,  $\mu_p = 7700 \text{ cm}^2/\text{Vs}$ ,  $\Delta = 66 \text{ meV}$ ,  $R_{d/s} = 120 \Omega \cdot \mu\text{m}$ , and  $m = 0.5 \text{ V}^2$ .

### C. Model Versus Measurements

In order to validate the model presented in this paper, a 20- $\mu\text{m} \times 15\text{-}\mu\text{m}$  back-gate GFET is fabricated and measured for comparison. The graphene used is CVD graphene transferred onto highly doped Si-SiO<sub>2</sub> wafer with the 80-nm thick Au contacts. The device was annealed for 12 h at 380 K in low vacuum, and the measurement was carried out when

the device returned to room temperature. During the fitting procedure, the modeling parameters, such as mobilities,  $n_{\text{pud}}$ , and  $R_{d/s}$ , are directly fitted on the measured  $I_{ds}$ . Fig. 9(a)–(c) shows good agreement between the modeled results and the measurements. In addition, the proposed model also achieves good matching with measurement data from [34] and [35] (see Figs. 10 and 11). It can also be seen from Fig. 10 that the transfer characteristics of GFET are accurately modeled for both the electron and hole conduction thanks to the improved carrier mobility analysis of this work. The fitting parameters used in Figs. 8, 10, and 11 are on the same level as those given in [20], [34], and [35].

## V. CONCLUSION

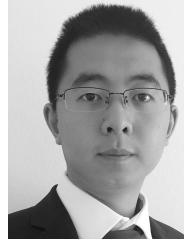
In summary, this paper presents a new concept of effective carrier mobility for GFET modeling. To the best of our knowledge, this is the first time that both the electron and hole mobility difference and the carrier-density-dependent mobility are included in a GFET model. The accurate approximation for saturation velocity proposed in this paper successfully eliminates the discontinuities in the simulated transconductance of GFET models using the two-region  $V_{\text{sat}}$ . The approximation for capacitance weighting factor  $\alpha$  proposed in this paper, allowing the transition from  $\alpha = 1$  (when  $q \times |V_{\text{ch}}| \gg kT$ ) to  $\alpha = 0.5$  (when  $q \times |V_{\text{ch}}| \ll kT$ ), guarantees the accuracy of the proposed model near the Dirac point and enables closed-form analytical solutions for the drain current. The Verilog-A code of the proposed model supports SPICE-like simulations in commercial simulators. The model has been validated against measurements, and excellent agreement has been achieved for both the electron and hole conduction simultaneously.

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